

## REFERENCES

1. J. Weiss, "Ion Chromatography", 2<sup>nd</sup> Ed, VCH, Germany, 1995
2. P. H. Kasai and F. P. Eng, "Silicone Oxide Formation in the Disk Environment", *J. Info. Storage Proc. Syst.*, 2000, **2**, 125-128
3. Infrared Spectroscopy Alas Working Committee, "An Infrared Spectroscopy Atlas for the Coatings Industry", 4<sup>th</sup> Ed, Vol 1 & Vol 2, Federation of Societies For Coatings Technology, USA, 1991
4. P.H. Schnabel, P.M. Lindley, D. Nehr Korn and M. Kendall, "Identifying the Types and Potential of Airborne Molecular Contaminants: A multi-Technique Approach", *Semiconductor Febtech*, 11<sup>th</sup> Ed, 2002, 123-129
5. T. MacDonald, "Designing a cleaner hard drive", *Datatech Online Journals*, 5<sup>th</sup> Ed, 2002  
<http://www.semiconductorfabtech.com/datatech/journals/index.shtml>
6. D. Hariharan and D. Krupa, "Pressure Sensitive Adhesive Suppliers Help Hard Disk Drive Manufacturers Control Contamination", *Datatech Online Journals*, 5<sup>th</sup> Ed, 2002
7. <http://www.threebond.co.jp/en/technical/categoryinformation/mobile/hdd/hdd1.html>

8. Evans Analytical Group, "Outgassing of Material", *Evans Analytical Group Application Notes*, 2002  
<http://www.eaglabs.com/appsnotes.htm>
9. K. Sattler and H.J. Feindt, "Thermal Separation Processes, Principles and Design", VCH, USA & Germany, 1995
10. "Loctite Worldwide Design Handbook" 1996/97 ed, Loctite Corporation, USA, 1996
11. A. S. Brar and P. B. Narayan, "Materials and Processing Failures in the Electroics and Computer Industries: Analysis and Prevention", ASM International, USA, 1994
12. A.R. Miller, "The Adsorption of Gases on Solids", The Syndics of the Cambridge University Press, New York, 1949
13. Braithwaite and F.J. Smith, "Chromatographic Methods", 5<sup>th</sup> Ed, Blackie Academic & Professional, NZ, 1996
14. C.L. Mantell, "Adsorption", 2<sup>nd</sup> Ed, McGraw.Hill Book Company, USA, 1951

15. E. Pfannkoch, J. Whitecavage, "Quantitative Determination of Trace Analytes in Solid Materials by Thermal Extraction GC", *Gerstel Application Notes*, Germany, 2001  
<http://www.gerstelus.com/apnotes.html>
16. Evans Analytical Group, "Analyze Slip Agents in Extruded Polyethylene Film", *Evans Analytical Group Application Notes*, 2002  
<http://www.eaglabs.com/appsnotes.htm>
17. Evans Analytical Group, "Analysis of Contaminants by DHS/GCMS", *Evans Analytical Group Application Notes*, 2002  
<http://www.eaglabs.com/appsnotes.htm>
18. H. Hachenberg and A.P. Schmidt, "Gas Chromatography Headspace Analysis", Heyden, London, 1977
19. Kolb, B (ed), "Applied Headspace Gas Chromatography", Heyden, London, 1980
20. Loffe, B.V. and Vitenberg, A.G., "Headspace and Related Methods in Gas Chromatography", John Wiley, London, 1984
21. P.N. Cheremisinoff and F. Ellerbusch, "Carbon Adsorption Handbook", Ann Arbor Science Publishers Inc. USA, 1978

32. "Gerstel CIS 4 and TDS 2 Operation Manual", Gerstel, Germany, 1998